The documentation and process conversion measures necessary to comply with this revision shall be completed by 27 October 2014

INCH-POUND

MIL-PRF-19500/704F
12 September 2014
SUPERSEDING
MIL-PRF-19500/704E
25 January 2013

PERFORMANCE SPECIFICATION SHEET

* SEMICONDUCTOR DEVICE, FIELD EFFECT RADIATION HARDENED
TRANSISTOR, N-CHANNEL,SILICON, TYPES 2N7485U3, 2N7486U3, 2N7487U3, AND 2N7555U3
JANTXVR AND JANSR

This specification is approved for use by all Departments and Agencies of the Department of Defense.

The requirements for acquiring the product described herein shall consist of this specification sheet and MIL-PRF-19500.

1. SCOPE

* 1.1 Scope. This specification covers the performance requirements for a N-channel, enhancement-mode, MOSFET, radiation hardened, power transistor. Two levels of product assurance are provided for each device type as specified in MIL-PRF-19500, with avalanche energy maximum rating (E_{AS}) and maximum avalanche current (I_{AS}). See 6.5 for JANHC and JANKC die versions.

1.2 Physical dimensions. See figure 1, (surface mount, TO-276AA, SMD-0.5).

1.3 Maximum ratings. T_A = +25°C, unless otherwise specified.

Type	P_T (1) T_C = +25°C	P_T T_A = +25°C	$R_{\theta JC}$ (2)	V_{DS}	V_{DG}	V_{GS}	I_{D1} (3) (4) T_C =+25°C	I_{D2} T_C = +100°C	I_S	I_{DM} (5)	T_J and T_{STG}	V_{ISO} 70,000 ft. altitude
	W	W	°C/W	V dc	V dc	V dc	A dc	A dc	A dc	A (pk)	°C	V dc
2N7485U3	75	2.5	1.67	130	130	±20	20	12.5	20	80	-55	N/A
2N7486U3	75	2.5	1.67	200	200	±20	12	7.8	12	48	to	N/A
2N7487U3	75	2.5	1.67	250	250	±20	10	6.4	10	40	+150	250
2N7555U3	75	2.5	1.67	250	250	±20	10	6.4	10	40	+150	250

(1) Derate linearly by 0.6 W/°C for T_C > +25°C.
(2) See figure 2, thermal impedance curves.
(3) The following formula derives the maximum theoretical I_D limit. I_D is limited by package and internal construction.

$$I_D = \sqrt{\frac{T_{JM} - T_C}{(R_{\theta JC}) \times (R_{DS}(on) \text{ at } T_{JM})}}$$

(4) See figure 3, maximum drain current graph.
(5) I_{DM} = 4 X I_{D1} as calculated in note (3).

Comments, suggestions, or questions on this document should be addressed to DLA Land and Maritime, ATTN: VAC, P.O. Box 3990, Columbus, OH 43218-3990, or emailed to Semiconductor@dla.mil. Since contact information can change, you may want to verify the currency of this address information using the ASSIST Online database at https://assist.dla.mil/.

1.4 Primary electrical characteristics at T_C = +25°C.

Type	Min $V_{(BR)DSS}$ V_{GS} = 0 I_D = 1.0mA dc	$V_{GS(TH)1}$ $V_{DS} \geq V_{GS}$ I_D = 1.0 mA dc		Max I_{DSS1} V_{GS} = 0 V_{DS} = 80% of rated V_{DS}	Max $r_{DS(on)}$ (1) V_{GS} = 12V, I_D = I_{D2}		E_{AS}
					T_J = +25°C	T_J = +150°C	
	V dc	V dc		µA dc	Ω	Ω	mJ
		Min	Max				
2N7485U3	130	2.5	4.5	10	0.080	0.184	65
2N7486U3	200	2.5	4.5	10	0.220	0.486	60
2N7487U3	250	2.5	4.5	10	0.400	0.780	58
2N7555U3	250	2.5	4.5	10	0.400	0.780	58

(1) Pulsed (see 4.5.1).

2. APPLICABLE DOCUMENTS

* 2.1 General. The documents listed in this section are specified in sections 3 and 4 of this specification. This section does not include documents cited in other sections of this specification or recommended for additional information or as examples. While every effort has been made to ensure the completeness of this list, document users are cautioned that they must meet all specified requirements of documents cited in sections 3 and 4 of this specification, whether or not they are listed.

2.2 Government documents.

2.2.1 Specifications, standards, and handbooks. The following specifications, standards, and handbooks form a part of this document to the extent specified herein. Unless otherwise specified, the issues of these documents are those cited in the solicitation or contract.

DEPARTMENT OF DEFENSE SPECIFICATIONS

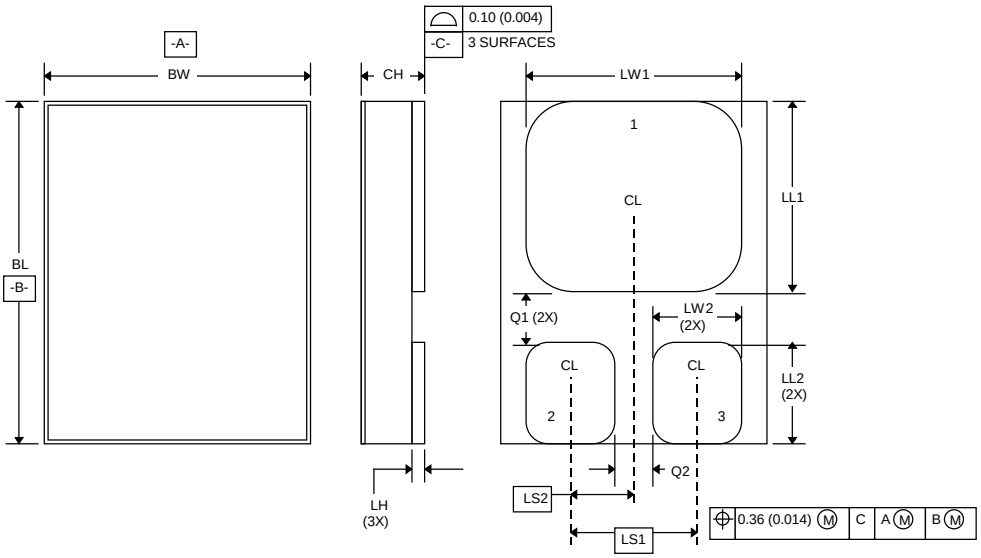
MIL-PRF-19500 - Semiconductor Devices, General Specification for.

DEPARTMENT OF DEFENSE STANDARDS

MIL-STD-750 - Test Methods for Semiconductor Devices.

* (Copies of these documents are available online at http://quicksearch.dla.mil.)

2.3 Order of precedence. Unless otherwise noted herein or in the contract, in the event of a conflict between the text of this document and the references cited herein, the text of this document takes precedence. Nothing in this document, however, supersedes applicable laws and regulations unless a specific exemption has been obtained.



Symbol	Dimensions			
	Inches		Millimeters	
	Min	Max	Min	Max
BL	.395	.405	10.03	10.29
BW	.291	.301	7.39	7.65
CH		.124		3.15
LH	.010	.020	0.25	0.51
LW1	.281	.291	7.14	7.39
LW2	.090	.100	2.29	2.54
LL1	.220	.230	5.59	5.84
LL2	.115	.125	2.92	3.18
LS1	.150 BSC		3.81 BSC	
LS2	.075 BSC		1.91 BSC	
Q1	.030		0.762	
Q2	.030		0.762	
TERM 1	Drain			
TERM 2	Gate			
TERM 3	Source			

NOTES:
1. Dimension are in inches.
2. Millimeters are given for information only.
3. The lid shall be electrically isolated from the drain, gate and source.
4. In accordance with ASME Y14.5M, diameters are equivalent to ϕx symbology.

FIGURE 1. Dimensions and configuration (TO-276AA, SMD-0.5).

3. REQUIREMENTS

3.1 General. The individual item requirements shall be as specified in MIL-PRF-19500 and as modified herein.

3.2 Qualification. Devices furnished under this specification shall be products that are manufactured by a manufacturer authorized by the qualifying activity for listing on the applicable qualified manufacturer's list (QML) before contract award (see 4.2 and 6.3).

3.3 Abbreviations, symbols, and definitions. Abbreviations, symbols, and definitions used herein shall be as specified in MIL-PRF-19500.

3.4 Interface and physical dimensions. Interface and physical dimensions shall be as specified in MIL-PRF-19500, and on figure 1 (TO-276AA, SMD-0.5) herein.

3.4.1 Lead finish. Lead finish shall be solderable in accordance with MIL-PRF-19500, MIL-STD-750, and herein. Where a choice of lead finish is desired, it shall be specified in the acquisition document (see 6.2).

3.4.2 Multiple chip construction. Multiple chip construction is not permitted to meet the requirements of this specification.

3.5 Electrostatic discharge (ESD) protection. The devices covered by this specification require electrostatic discharge protection (see 3.5.1).

3.5.1 Handling. Metal oxide semiconductor (MOS) devices must be handled with certain precautions to avoid damage due to the accumulation of static charge. However, the following handling practices are recommended (see 3.5).

a. Devices should be handled on benches with conductive handling devices.

b. Ground test equipment, tools, and personnel handling devices.

c. Do not handle devices by the leads.

d. Store devices in conductive foam or carriers.

e. Avoid use of plastic, rubber or silk in MOS areas.

f. Maintain relative humidity above 50 percent if practical.

g. Care should be exercised during test and troubleshooting to apply not more than maximum rated voltage to any lead.

h. Gate must be terminated to source, $R \leq$ or 100 kΩ, whenever bias voltage is applied drain to source.

3.6 Electrical performance characteristics. Unless otherwise specified herein, the electrical performance characteristics are as specified in 1.3, 1.4, and table I.

3.7 Electrical test requirements. The electrical test requirements shall be as specified in table I.

3.8 Marking. Marking shall be in accordance with MIL-PRF-19500.

3.9 Workmanship. Semiconductor devices shall be processed in such a manner as to be uniform in quality and shall be free from other defects that will affect life, serviceability, or appearance.

4. VERIFICATION

4.1 Classification of inspections. The inspection requirements specified herein are classified as follows:

a. Qualification inspection (see 4.2).

b. Screening (see 4.3).

c. Conformance inspection (see 4.4 and tables I and II).

4.2 Qualification inspection. Qualification inspection shall be in accordance with MIL-PRF-19500.

4.2.1 Group E qualification. Group E inspection shall be performed for qualification or re-qualification only. In case qualification was awarded to a prior revision of the specification sheet that did not request the performance of table III tests, the tests specified in table III herein that were not performed in the prior revision shall be performed on the first inspection lot of this revision to maintain qualification.

* 4.2.1.1 Single event effects SEE. SEE shall be performed at initial qualification and after process or design changes which may affect radiation hardness (see table III and table IV). Upon qualification, manufacturers shall provide the verification test conditions from section 5 of method 1080 of MIL-STD-750 that were used to qualify the device for inclusion into section 6 of the slash sheet. End-point measurements shall be in accordance with table II. SEE characterization data shall be made available upon request of the qualifying or acquiring activity.

* 4.3 Screening (JANS and JANTXV). Screening shall be in accordance with table E-IV of MIL-PRF-19500, and as specified herein. The following measurements shall be made in accordance with table I herein. Devices that exceed the limits of table I herein shall not be acceptable.

Screen (see table E-IV of MIL-PRF-19500) (1) (2)	Measurement	
	JANS	JANTXV
(3)	Gate stress test (see 4.3.1)	Gate stress test (see 4.3.1)
(3)	Method 3470 of MIL-STD-750, E_{AS} (see 4.3.2)	Method 3470 of MIL-STD-750, E_{AS} (see 4.3.2)
(3) 3c	Method 3161 of MIL-STD-750, thermal impedance, (see 4.3.3)	Method 3161 of MIL-STD-750, thermal impedance, (see 4.3.3)
9	Subgroup 2 of table I herein I_{GSSF1}, I_{GSSR1}, I_{DSS1} as a minimum	Not applicable
10	Method 1042 of MIL-STD-750, test condition B	Method 1042 of MIL-STD-750, test condition B
11	I_{GSSF1}, I_{GSSR1}, I_{DSS1}, $r_{DS(ON)1}$, $V_{GS(TH)1}$ Subgroup 2 of table I herein. ΔI_{GSSF1} = ±20 nA dc or ±100 percent of initial value, whichever is greater. ΔI_{GSSR1} = ±20 nA dc or ±100 percent of initial value, whichever is greater. ΔI_{DSS1} = ±10 μA dc or ±100 percent of initial value, whichever is greater.	I_{GSSF1}, I_{GSSR1}, I_{DSS1}, $r_{DS(ON)1}$, $V_{GS(TH)1}$ Subgroup 2 of table I herein.
12	Method 1042 of MIL-STD-750, test condition A	Method 1042 of MIL-STD-750, test condition A
13	Subgroups 2 and 3 of table I herein ΔI_{GSSF1} = ±20 nA dc or ±100 percent of initial value, whichever is greater. ΔI_{GSSR1} = ±20 nA dc or ±100 percent of initial value, whichever is greater. ΔI_{DSS1} = ±10 μA dc or ±100 percent of initial value, whichever is greater. $\Delta r_{DS(ON)1}$ = ±20 percent of initial value. $\Delta V_{GS(TH)1}$ = ±20 percent of initial value.	Subgroup 2 of table I herein ΔI_{GSSF1} = ±20 nA dc or ±100 percent of initial value, whichever is greater. ΔI_{GSSR1} = ±20 nA dc or ±100 percent of initial value, whichever is greater. ΔI_{DSS1} = ±10 μA dc or ±100 percent of initial value, whichever is greater. $\Delta r_{DS(ON)1}$ = ±20 percent of initial value. $\Delta V_{GS(TH)1}$ = ±20 percent of initial value.
17	For U3 packages: Method 1081 of MIL-STD-750 (see 4.3.4), Endpoints: Subgroup 2 of table I herein.	For U3 packages: Method 1081 of MIL-STD-750 (see 4.3.4), Endpoints: Subgroup 2 of table I herein

(1) At the end of the test program, I_{GSSF1}, I_{GSSR1}, and I_{DSS1} are measured.

* (2) An out-of-family program to characterize I_{GSSF1}, I_{GSSR1}, I_{DSS1}, $V_{GS(th)1}$ and $_{RDS(ON)1}$ shall be invoked..

(3) Shall be performed anytime after temperature cycling, screen 3a. JANTX and JANTXV levels do not need to be repeated in screening requirements.

4.3.1 Gate stress test. Apply V_{GS} = 24 V minimum for t = 250 μs minimum.

4.3.2 Single pulse avalanche energy (E_{AS}).

a. Peak current .....$I_{AS} = I_{D1}$.

b. Inductance: ..... $\left[\frac{2E_{AS}}{(I_{D1})^2}\right]\left[\frac{V_{BR} - V_{DD}}{V_{BR}}\right]$ mH minimum.

c. Gate to source resistor (R_{GS}).....$25 \leq R_{GS} \leq 200\ \Omega$.

d. Supply voltage (V_{DD}).....V_{DD} = 25 V dc, except V_{DD} = 50 V dc for 2N7487U3 and 2N7555U3.

e. Peak gate voltage (V_{GS}).....12 V.

f. Initial case temperature .....T_C = +25°C +10°C, -5°C.

g. Number of pulses to be applied .....1 pulse minimum.

4.3.3 Thermal impedance. The thermal impedance measurements shall be performed in accordance with method 3161 of MIL-STD-750 using the guidelines in that method for determining I_M, I_H, t_H, t_{SW}, (and V_H where appropriate). Measurement delay time (t_{MD}) = 70 μs max. See table III, group E, subgroup 4 herein.

* 4.3.4 Dielectric withstanding voltage.

a. Magnitude of test voltage……600 V dc.

b. Duration of application of test voltage……..15 seconds (min).

c. Points of application of test voltage……..All terminals to case.

d. Method of connection……..Mechanical.

e. Kilovolt-ampere rating of high voltage source…….1,200 V/1.0 mA (min).

f. Maximum leakage current……...1.0 mA.

g. Voltage ramp up time.....500 V/second

4.4 Conformance inspection. Conformance inspection shall be in accordance with MIL-PRF-19500.

4.4.1 Group A inspection. Group A inspection shall be conducted in accordance with table E-V of MIL-PRF-19500 and table I herein.

4.4.2 Group B inspection. Group B inspection shall be conducted in accordance with the conditions specified for subgroup testing in table E-VIA (JANS) and table E-VIB (JANTXV) of MIL-PRF-19500, and as follows. Electrical measurements (end-points) shall be in accordance with table I, subgroup 2 herein.

* 4.4.2.1 Group B inspection, table E-VIA (JANS) of MIL-PRF-19500.

Subgroup	Method	Condition
B3	1051	Test condition G, 100 cycles.
B3	2077	Scanning electron microscope (SEM).
B4	1042	Intermittent operation life, condition D, t_{on} = 30 seconds minimum.
B5	1042	Accelerated steady-state gate bias, condition B, V_{GS} = rated; T_A = +175°C, t = 24 hours minimum; or T_A = +150°C, t = 48 hours minimum.
B5	1042	Accelerated steady-state reverse bias, condition A, V_{DS} = rated; T_A = +175°C, t = 120 hours minimum; or T_A = +150°C, t = 240 hours minimum.
B5	2037	Bond strength, test condition D.

* 4.4.2.2 Group B inspection, table E-VIB (JANTXV) of MIL-PRF-19500.

Subgroup	Method	Condition
B2	1051	Test condition G, 25 cycles.
B3	1042	Intermittent operation life, condition D, t_{on} = 30 seconds minimum.
B5 and B6		Not applicable.

* 4.4.3 Group C inspection. Group C inspection shall be conducted in accordance with the conditions specified for subgroup testing in table E-VII of MIL-PRF-19500 and as follows. Electrical measurements (end-points) shall be in accordance with table I, subgroup 2 herein.

Subgroup	Method	Condition
C2	2036	Terminal strength is not applicable.
C5	3161	See 4.3.3.
C6	1042	Intermittent operation life, condition D, t_{on} = 30 seconds minimum.

4.4.4 Group D inspection. Group D inspection shall be conducted in accordance with table E-VIII of MIL-PRF-19500 and table II herein.

4.4.5 Group E inspection. Group E inspection shall be conducted in accordance with MIL-PRF-19500, and table III herein. Electrical measurements (end-points) shall be in accordance with table I, subgroup 2 herein.

4.5 Methods of inspection. Methods of inspection shall be as specified in the appropriate tables and as follows.

4.5.1 Pulse measurements. Conditions for pulse measurement shall be as specified in section 4 of MIL-STD-750.

TABLE I. Group A inspection.

Inspection 1/	MIL-STD-750		Symbol	Limits		Unit
	Method	Condition		Min	Max	
Subgroup 1						
Visual and mechanical inspection	2071					
Subgroup 2						
Thermal impedance 2/	3161	See 4.3.3	$Z_{\theta JC}$			°C/W
Breakdown voltage drain to source	3407	Bias condition C, V_{GS} = 0 V, I_D = 1 mA dc	$V_{(BR)DSS}$			
2N7485U3				130		V dc
2N7486U3				200		V dc
2N7487U3				250		V dc
2N7555U3				250		V dc
Gate to source voltage (threshold)	3403	$V_{DS} \geq V_{GS}$, I_D = 1 mA dc	$V_{GS(TH)1}$	2.5	4.5	V dc
Gate current	3411	V_{GS} = +20 V dc, bias condition C, V_{DS} = 0 V	I_{GSSF1}		+100	nA dc
Gate current	3411	V_{GS} = -20 V dc, bias condition C, V_{DS} = 0 V	I_{GSSR1}		-100	nA dc
Drain current	3413	V_{GS} = 0 V dc, bias condition C, V_{DS} = 80 percent of rated V_{DS},	I_{DSS1}		10	µA dc
Static drain to source on-state resistance	3421	V_{GS} = 12 V dc, condition A, pulsed (see 4.5.1), $I_D = I_{D2}$	$r_{DS(ON)1}$			
2N7485U3					0.080	Ω
2N7486U3					0.220	Ω
2N7487U3					0.400	Ω
2N7555U3					0.400	Ω
Forward voltage	4011	V_{GS} = 0 V dc, condition A, pulsed (see 4.5.1), $I_D = I_{D1}$	V_{SD}		1.2	V dc

See footnotes at end of table.

TABLE I. Group A inspection - Continued.

Inspection 1/	MIL-STD-750		Symbol	Limits		Unit
	Method	Condition		Min	Max	
Subgroup 3						
High temperature operation		$T_C = T_J = +125°C$				
Gate current	3411	$V_{GS} = \pm 20$ V dc, bias condition C, $V_{DS} = 0$ V	I_{GSS2}		±200	nA dc
Drain current	3413	$V_{GS} = 0$ V dc, bias condition C, V_{DS} = 80 percent of rated V_{DS}	I_{DSS2}		25	µA dc
Static drain to source on-state resistance	3421	V_{GS} = 12 V dc, condition A, pulsed (see 4.5.1), $I_D = I_{D2}$	$r_{DS(ON)3}$			
2N7485U3					0.160	Ω
2N7486U3					0.462	Ω
2N7487U3					0.750	Ω
2N7555U3					0.750	Ω
Gate to source voltage (threshold)	3403	$V_{DS} \geq V_{GS}$, I_D = 1 mA dc	$V_{GS(TH)2}$	1.5		V dc
Low temperature operation		$T_C = T_J = -55°C$				
Gate to source voltage (threshold)	3403	$V_{DS} \geq V_{GS(TH)3}$, I_D = 1 mA dc	$V_{GS(TH)3}$		5.5	V dc
Subgroup 4						
Forward transconductance	3475	$I_D = I_{D2}$, V_{DD} = 15 V dc (see 4.5.1)	g_{FS}			
2N7485U3				8		S
2N7486U3				6		S
2N7487U3				6		S
2N7555U3				3		S
Switching time test	3472	$I_D = I_{D1}$, V_{GS} = 12 V dc, R_G = 7.5 Ω, V_{DD} = 50 percent of rated V_{DS}				
Turn-on delay time			$t_{D(on)}$			
2N7485U3					20	ns
2N7486U3					25	ns
2N7487U3					25	ns
2N7555U3					25	ns
Rise time			t_r		100	ns
Turn-off delay time			$t_{D(off)}$		35	ns
Fall time			t_f			
2N7485U3					40	ns
2N7486U3					30	ns
2N7487U3					30	ns
2N7555U3					30	ns

See footnotes at end of table.

TABLE I. Group A inspection - Continued.

Inspection 1/	MIL-STD-750		Symbol	Limits		Unit
	Method	Condition		Min	Max	
Subgroup 5						
Safe operating area test	3474	See figure 4 t_p = 10 ms min. V_{DS} = 80 percent of max. rated V_{DS}				
Electrical measurements		See table I, subgroup 2				
Subgroup 6						
Not applicable						
Subgroup 7						
Gate charge	3471	Condition B, $I_D = I_{D1}$, V_{GS} = 12 V dc V_{DD} = 50 percent of rated V_{DS}				
On-state gate charge			$Q_{G(ON)}$			
2N7485U3					48	nC
2N7486U3					35	nC
2N7487U3					28	nC
2N7555U3					32	nC
Gate to source charge			Q_{GS}			
2N7485U3					16	nC
2N7486U3					9	nC
2N7487U3					7.4	nC
2N7555U3					11	nC
Gate to drain charge			Q_{GD}			
2N7485U3					18	nC
2N7486U3					15	nC
2N7487U3					12	nC
2N7555U3					16	nC
Reverse recovery time	3473	di/dt = -100 A/μs, V_{DD} ≤ 50 V $I_D = I_{D1}$	t_{rr}			
2N7485U3					250	ns
2N7486U3					300	ns
2N7487U3					300	ns
2N7555U3					300	ns

1/ For sampling plan, see MIL-PRF-19500.
2/ This test is required for the following end-point measurement only (not intended for 4.3, screen 9 or 11): JANS table E-VIA of MIL-PRF-19500, group B, subgroups 3 and 4; JANTXV, table E-VIB of MIL-PRF-19500, group B, subgroups 2 and 3; and table E-VII of MIL-PRF-19500, group C, subgroups 2 and 6, and table E-IX of MIL-PRF-19500, group E, subgroup 1.

TABLE II. Group D inspection.

Inspection 1/ 2/ 3/	MIL-STD-750		Symbol	Pre-irradiation limits		Post-irradiation limits		Unit
	Method	Conditions		R		R		
				Min	Max	Min	Max	
Subgroup 1								
Not applicable								
Subgroup 2		T_C = + 25°C						
Steady-state total dose irradiation (V_{GS} bias) 4/	1019	V_{GS} = 12 V; V_{DS} = 0						
Steady-state total dose irradiation (V_{DS} bias) 4/	1019	V_{GS} = 0; V_{DS} = 80 percent of rated V_{DS}(preirradiation)						
End-point electricals:								
Breakdown voltage, drain to source	3407	Bias condition C, V_{GS} = 0; I_D = 1 mA	$V_{(BR)DSS}$					
2N7485U3				130		130		V dc
2N7486U3				200		200		V dc
2N7487U3				250		250		V dc
2N7555U3				250		250		V dc
Gate to source voltage (threshold)	3403	$V_{DS} \geq V_{GS}$ I_D = 1 mA	$V_{GS(th)1}$	2.5	4.5	2.0	4.5	V dc
Gate current	3411	Bias condition C, V_{GS} = +20 V; V_{DS} = 0	I_{GSSF1}		100		100	nA dc
Gate current	3411	Bias condition C, V_{GS} = -20 V; V_{DS} = 0	I_{GSSR1}		-100		-100	nA dc
Drain current	3413	Bias condition C, V_{GS} = 0 V_{DS} = 80 percent of rated V_{DS} (preirradiation)	I_{DSS}		10		10	µA dc
Static drain to source on-state voltage	3405	V_{GS} = 12 V; I_D = I_{D2} condition A, pulsed (see 4.5.1)	$V_{DS(on)}$					
2N7485U3					1.025		1.025	V dc
2N7486U3					1.732		1.732	V dc
2N7487U3					2.586		2.586	V dc
2N7555U3					2.586		2.586	V dc
Forward voltage source drain diode	4011	Bias condition C, V_{GS} = 0; I_D = I_{D1}	V_{SD}		1.2		1.2	V dc

1/ For sampling plan see MIL-PRF-19500.
2/ Group D qualification may be performed prior to lot formation. Wafers qualified to these group D QCI requirements may be used for any other specification sheets utilizing the same die design.
3/ At the manufacturer's option, group D samples need not be subjected to the screening tests, and may be assembled in it's qualified package or in any qualified package that the manufacturer has data to correlate the performance to the designated package.
4/ Separate samples shall be pulled for each bias.

* TABLE III. Group E inspection (all quality levels) for qualification or re-qualification only.

Inspection	MIL-STD-750		Qualification and large lot quality conformance inspection
	Method	Conditions	
Subgroup 1			45 devices c = 0
Temperature cycling	1051	-55°C to +150°C, 500 cycles	
Hermetic seal Fine leak Gross leak	1071	As applicable	
Electrical measurements		See table I, subgroup 2 herein.	
Subgroup 2 1/			45 devices c = 0
Steady-state gate bias	1042	Condition B, 1,000 hours.	
Electrical measurements		See table I, subgroup 2 herein.	
Steady-state reverse bias	1042	Condition A, 1,000 hours.	
Electrical measurements		See table I, subgroup 2 herein.	
Subgroup 4			Sample size N/A
Thermal impedance curves		See MIL-PRF-19500.	
Subgroup 5			15 devices c = 0
Barometric pressure 2N7487U3 and 2N7555U3	1001	Test condition C.	
Subgroup 10			22 devices c = 0
Commutating diode for safe operating area test procedure for measuring dv/dt during reverse recovery of power MOSFET transistors or insulated gate bipolar transistors	3476	Test conditions shall be derived by the manufacturer	

See footnotes at end of table.

* TABLE III. Group E inspection (all quality levels) for qualification or re-qualification only - Continued.

Inspection	MIL-STD-750		Qualification and large lot quality conformance inspection
	Method	Conditions	
Subgroup 11 SEE 2/ 3/	1080	See MIL-STD-750 method 1080 and 6.2.	3 devices

1/ A separate sample for each test shall be pulled.
2/ Group E qualification of SEE testing may be performed prior to lot formation. Qualification may be extended to other specification sheets utilizing the same structurally identical die design.
3/ Device qualification to a higher level linear energy transfer (LET) is sufficient to qualify all lower level LETs.

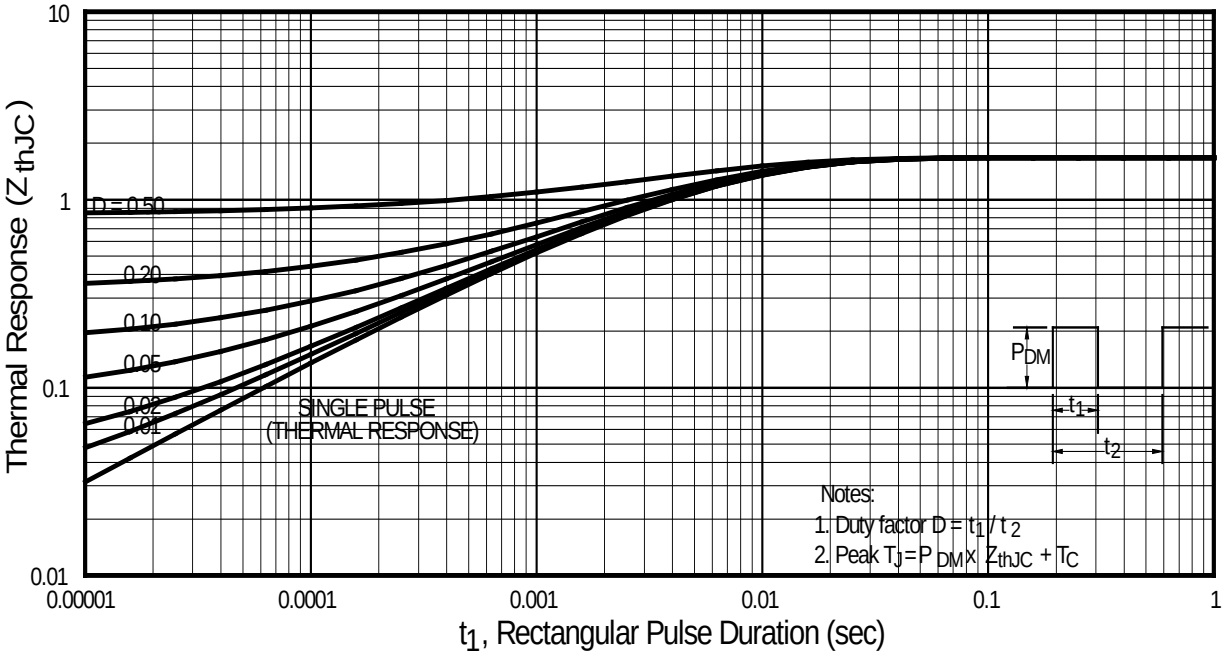
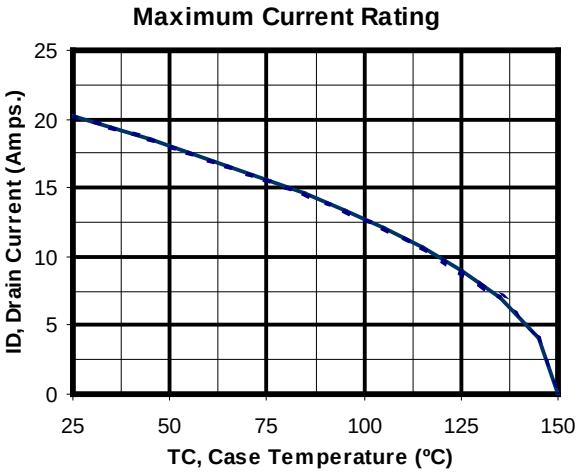


FIGURE 2. Thermal response curve.



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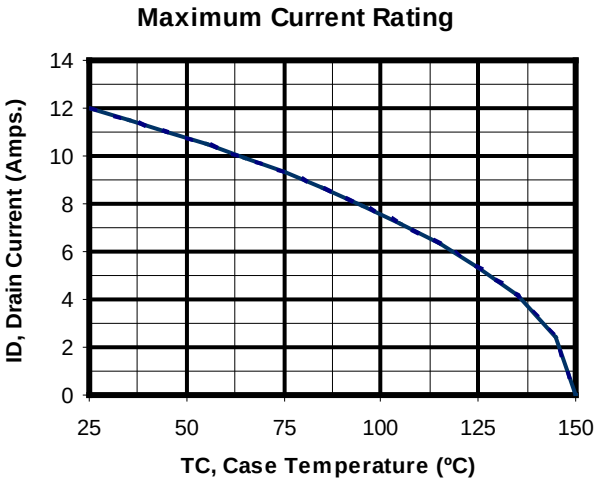

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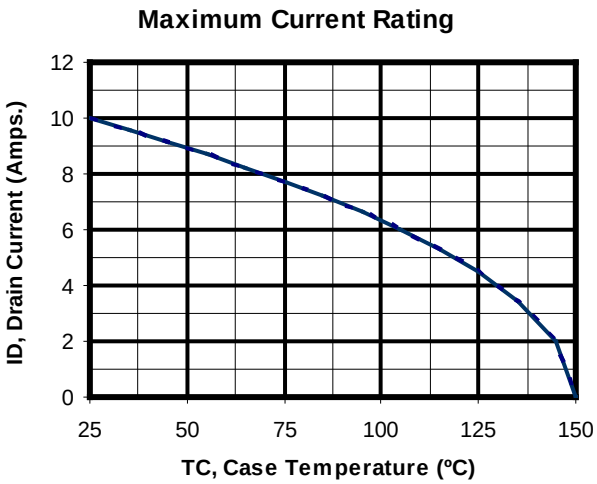
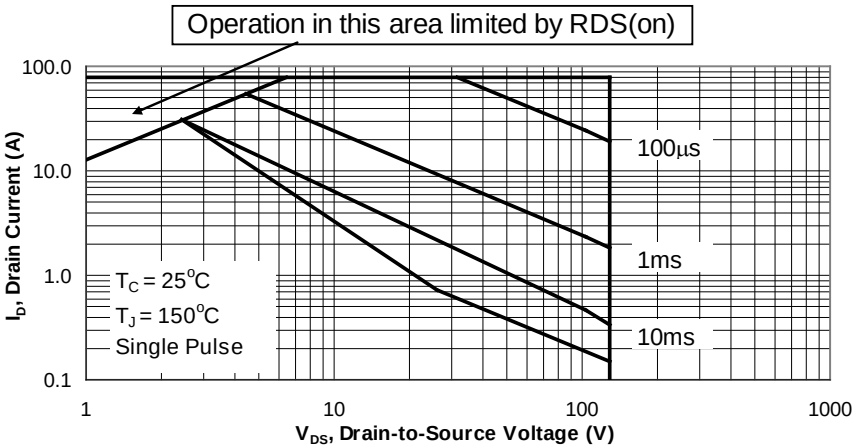


2N7487U3 and 2N7555U3

FIGURE 3. Maximum drain current versus case temperature graphs.

2N7485U3



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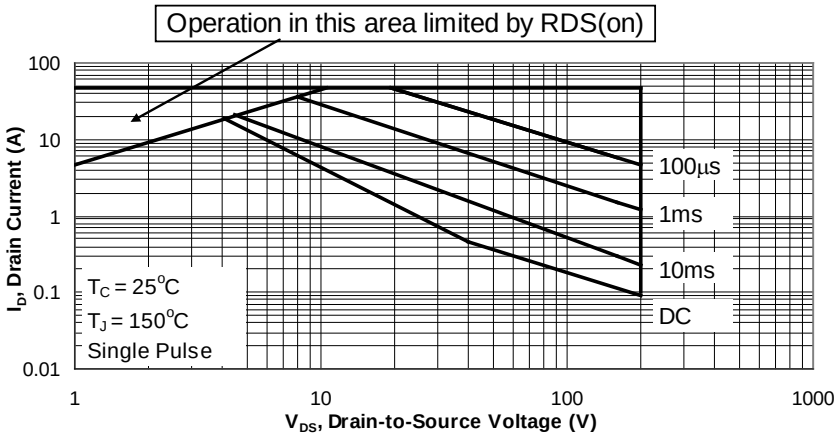

FIGURE 4. Safe operating area graph.

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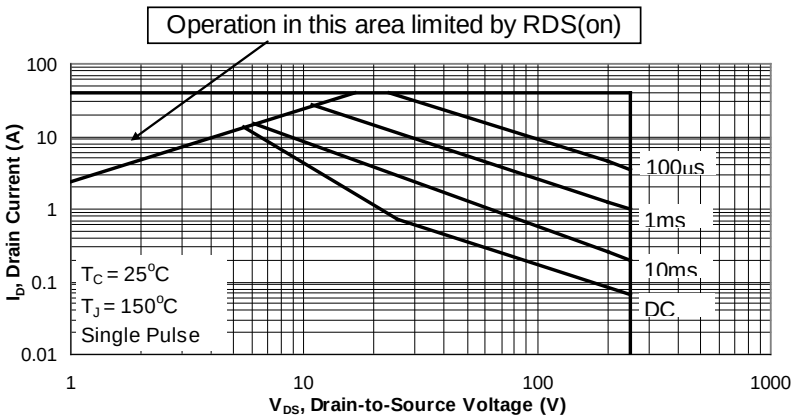


2N7555U3

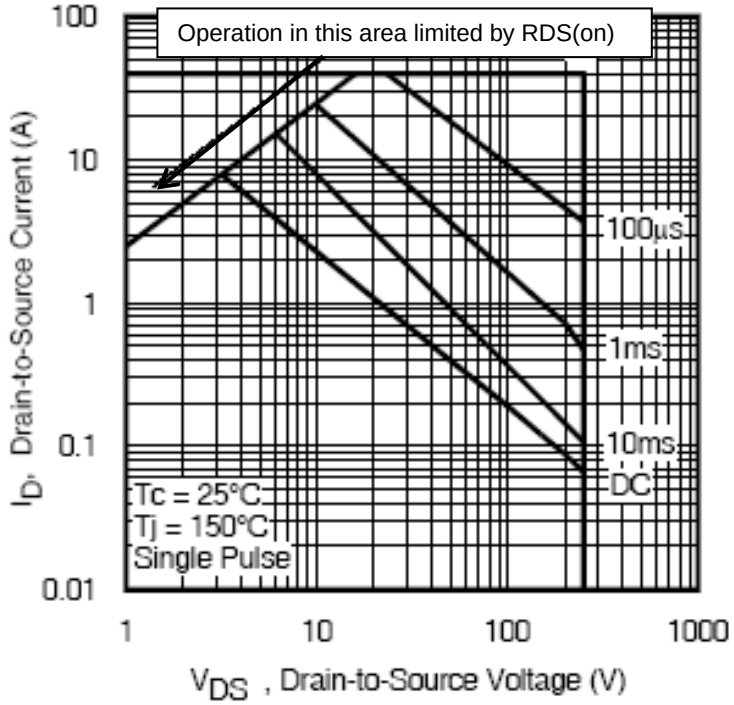


FIGURE 4. Safe operating area graph - Continued.

5. PACKAGING

5.1 Packaging. For acquisition purposes, the packaging requirements shall be as specified in the contract or order (see 6.2). When packaging of materiel is to be performed by DoD or in-house contractor personnel, these personnel need to contact the responsible packaging activity to ascertain packaging requirements. Packaging requirements are maintained by the Inventory Control Point's packaging activities within the Military Service or Defense Agency, or within the Military Service's system commands. Packaging data retrieval is available from the managing Military Department's or Defense Agency's automated packaging files, CD-ROM products, or by contacting the responsible packaging activity.

6. NOTES

(This section contains information of a general or explanatory nature that may be helpful, but is not mandatory. The notes specified in MIL-PRF-19500 are applicable to this specification.)

6.1 Intended use. Semiconductors conforming to this specification are intended for original equipment design applications and logistic support of existing equipment.

* 6.2 Acquisition requirements. Acquisition documents should specify the following:

a. Title, number, and date of this specification.

b. Packaging requirements (see 5.1).

c. Lead finish (see 3.4.1).

d. The complete Part or Identifying Number (PIN), see title and section 1.

e. For acquisition of RHA designated devices, table II, subgroup 1 testing of group D herein is optional. If subgroup 1 is desired, it should be specified in the contract.

f. If specific SEE characterization conditions are desired (see 6.6 and table IV), manufacturer's cage code should be specified in the contract or order.

6.3 Qualification. With respect to products requiring qualification, awards will be made only for products which are, at the time of award of contract, qualified for inclusion in Qualified Manufacturers List (QML 19500) whether or not such products have actually been so listed by that date. The attention of the contractors is called to these requirements, and manufacturers are urged to arrange to have the products that they propose to offer to the Federal Government tested for qualification in order that they may be eligible to be awarded contracts or orders for the products covered by this specification. Information pertaining to qualification of products may be obtained from DLA Land and Maritime, ATTN: VQE, P.O. Box 3990, Columbus, OH 43218-3990 or e-mail vqe.chief@dla.mil. An online listing of products qualified to this specification may be found in the Qualified Products Database (QPD) at https://assist.dla.mil.

6.4 Substitution information. Devices covered by this specification are substitutable for the manufacturer's and user's Part or Identifying Number (PIN) (without JAN and RHA prefix). This information in no way implies that manufacturer's PINs are substitutable for the military PIN.

Preferred types military PIN	Commercial PIN
2N7485U3	IRHNJ57133SE
2N7486U3	IRHNJ57230SE
2N7487U3 (obsolete)	IRHNJ57234SE
2N7555U3 (2N7487U3 replacement)	IRHNJ57234SE

6.5 JANC die versions. The JANHC and JANKC die versions of these devices are covered under specification sheet MIL-PRF-19500/741.

* 6.6 Application data.

* 6.6.1 Manufacturer specific irradiation data. Each manufacturer qualified to this slash sheet has characterized its devices to the requirements of MIL-STD-750 method 1080 and as specified herein. Since each manufacturer's characterization conditions can be different and can vary by the version of method 1080 qualified to, the MIL-STD-750 method 1080 revision version date and conditions used by each manufacturer for characterization have been listed here (see table IV) for information only. SEE conditions and figures listed in section 6 are current as of the date of this specification sheet, please contact the manufacturer for the most recent conditions.

TABLE IV. Manufacturers characterization conditions.

Manufactures CAGE	Inspection	MIL-STD-750		Sample plan
		Method	Conditions	
69210 (Applicable to devices with a date code of 2 February 1998 and older)	SEE 1/	1080	See MIL-STD-750 method 1080. See figure 5.	3 devices
	Electrical measurements		I_{GSSF1}, I_{GSSR1}, and I_{DSS1} in accordance with table I, subgroup 2	
	SEE Irradiation:		Fluence = 3E5 ±20 percent ions/cm^2 Flux = 2E3 to 2E4 ions/cm^2/sec, temperature = 25 ±5°C Surface LET = 38 MeV-cm^2/mg ±5%, range = 38 µm ±7.5%, energy = 300 MeV ±7.5%	
	2N7485U3		In situ bias conditions: V_{DS} = 130 V and V_{GS} = -20 V (typical 3.75 MeV/Nucleon at Texas A&M Cyclotron)	
	2N7486U3		In situ bias conditions: V_{DS} = 200 V and V_{GS} = -20 V (nominal 3.86 MeV/Nucleon at Brookhaven National Lab Accelerator)	
	2N7487U3 and 2N7555U3		In situ bias conditions: V_{DS} = 250 V and V_{GS} = -20 V nominal 3.86 MeV/Nucleon at Brookhaven National Lab Accelerator) Surface LET = 61 MeV-cm^2/mg ±5 percent, Range = 31 µm ±10%, energy = 330 MeV ±7.5%, Energy = 305 MeV +/- 7.5 percent	
	2N785U3		In situ bias conditions: V_{DS} = 130 V and V_{GS} = -10 V V_{DS} = 100 V and V_{GS} = -15 V V_{DS} = 50 V and V_{GS} = -20 V (typical 2.70 MeV/Nucleon at Texas A&M Cyclotron)	
	2N7486U3		In situ bias conditions: V_{DS} = 200 V and V_{GS} = -10 V V_{DS} = 185 V and V_{GS} = -15 V V_{DS} = 120 V and V_{GS} = -20 V (nominal 2.92 MeV/Nucleon at Brookhaven National Lab Accelerometer)	
	2N7487U3 and 2N7555U3		In-situ bias conditions: V_{DS} = 250 V and V_{GS} = -15 V V_{DS} = 240 V and V_{GS} = -20 V (nominal 2.92 MeV/nucleon at Brookhaven National Lab Accelerator)	

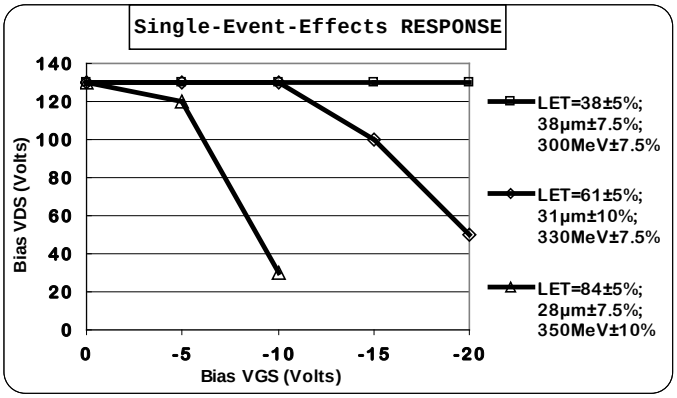
See footnotes at end of table.

TABLE IV. Manufacturers characterization conditions – Continued.

Manufactures CAGE	Inspection	MIL-STD-750		Sample plan	
		Method	Conditions		
			Surface LET = 84 MeV-cm^2/mg ±5%, range = 28 µm ±7.5%, energy = 350 MeV ±10%		
	2N7485U3		In-situ bias conditions: V_{DS} = 130 V and V_{GS} = 0 V V_{DS} = 120 V and V_{GS} = -5 V V_{DS} = 30 V and V_{GS} = - 10 V (typical 1.89 MeV/nucleon at Texas A & M Cyclotron)		
	2N7486U3		In-situ bias conditions: V_{DS} = 200 V and V_{GS} = -5V V_{DS} = 150 V and V_{GS} = -10 V V_{DS} = 50 V and V_{GS} = -15 V V_{DS} = 25 V and V_{GS} = -20 V (nominal 1.98 MeV/nucleon at Brookhaven National Lab Accelerator)		
	2N7487U3 and 2N7555U3		In-situ bias conditions: V_{DS} = 250 V and V_{GS} = -5 V V_{DS} = 225 V and V_{GS} = -10 V V_{DS} = 175 V and V_{GS} = -15 V V_{DS} = 50 V and V_{GS} = -20 V (nominal 1.98 MeV/nucleon at Brookhaven National Lab Accelerator)		
	Electrical measurements		I_{GSSF1}, I_{GSSR1}, and I_{DSS1} in accordance with table I, subgroup 2		
Upon qualification, all manufacturers will provide the verification test conditions to be added to this table.					

1/ I_{GSSF1}, I_{GSSR1}, and I_{DSS1} was examined before and following SEE irradiation to determine acceptability for each bias condition. Other test conditions in accordance with table I, subgroup 2, may be performed at the manufacturer's option.

2N7485U3



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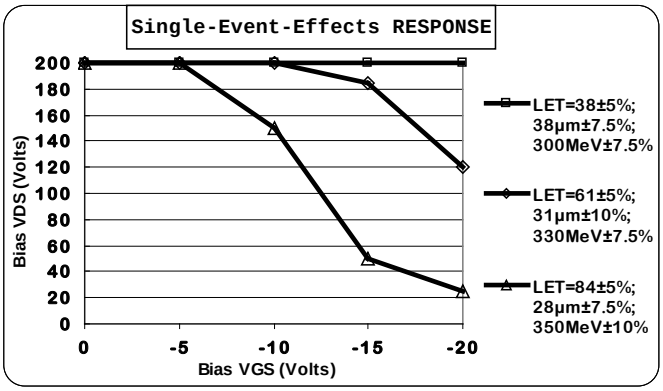

2N7487U3 and 2N7555U3

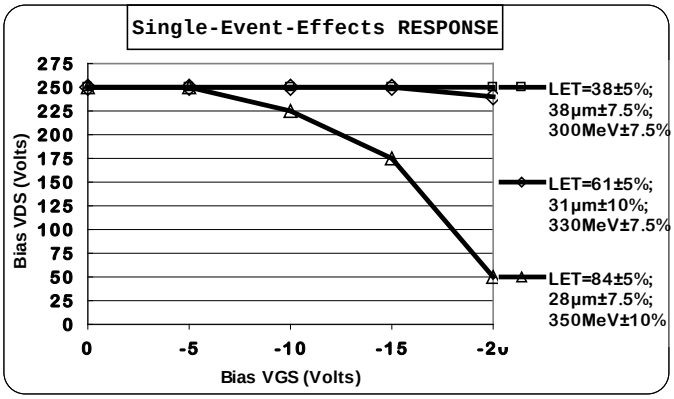

FIGURE 5. Typical SEE safe operating area graph.

* 6.7 Changes from previous issue. The margins of this specification are marked with asterisks to indicate where changes from the previous issue were made. This was done as a convenience only and the Government assumes no liability whatsoever for any inaccuracies in these notations. Bidders and contractors are cautioned to evaluate the requirements of this document based on the entire content irrespective of the marginal notations and relationship to the previous issue.

Custodians:
Army - CR
Navy - EC
Air Force - 85
NASA - NA
DLA - CC

Review activity:
Air Force - 99

Preparing activity:
DLA - CC

(Project 5961-2014-123)

NOTE: The activities listed above were interested in this document as of the date of this document. Since organizations and responsibilities can change, you should verify the currency of the information above using the ASSIST Online database at https://assist.dla.mil/.